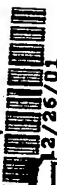


31002 U.S. PTO  
10/025783



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PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10025783	12/26/2001	430	5	1756	
APPLICANTS: Watanabe Miroru;					
**CONTINUING DATA VERIFIED: THIS APPLICATION IS A CON OF 09/443,500 11/19/1999 US 6,373,389					
** FOREIGN APPLICATIONS VERIFIED:					
PG-PUB DO NOT PUBLISH <input type="checkbox"/> RESCIND <input type="checkbox"/>					
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no				ATTORNEY DOCKET NO	
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no				MAE 223 C1	
Verified and Acknowledged Examiners's initials:					
TITLE : Method and apparatus for forming resist pattern					

U.S. DEPT. OF COMMERCE PAT. & TM. PTO-430 (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
4-1403		Total Claims	Print Claim for O.G.
		26 24	1
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
0		4	16
KATHLEEN DUDA PRIMARY EXAMINER Kathleen Duda Primary Examiner		Print Fig.	2E
<input checked="" type="checkbox"/> TERMINAL DISCLAIMER		Sias Application Examiner	
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